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On: FEBRUARY 7, 2003

By:

LINDA E. HASTINGS

Any fee due as a result of this paper, not covered by an enclosed check, may be charged on Deposit Acct. No. 50-1290.

**ATTORNEY DOCKET NO. NECK 17.552 (100806 -17282)**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

RECEIVED  
FEB 11 2003  
TECHNOLOGY CENTER 2800

Inventor: Hiroshi TANABE

Serial No.: 09/614,286

Filed: July 12, 2000

Title: **METHOD FOR FORMING SEMICONDUCTOR FILMS  
AT DESIRED POSITIONS ON A SUBSTRATE**

Examiner: Timothy J. Sutton

Group Art Unit: 2813

Commissioner for Patents  
Washington, D.C. 20231

**RESPONSE TO OFFICE ACTION**

Sir:

In response to the Office Action mailed on November 8, 2002, the period for responding thereto expiring after February 8, 2002, please amend the subject application as follows: